	Application No.	Applicant(s)
Notice of Allowability	10/617,451 Examiner	NGO ET AL.
	Walter L. Lindsay, Jr.	2812
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT ROOf the Office or upon petition by the applicant. See 37 CFR 1.313	ears on the cover sheet with the co (OR REMAINS) CLOSED in this application or other appropriate communication IGHTS. This application is subject to	plication. If not included will be mailed in due course. THIS
1. X This communication is responsive to to an After Final Amendment filed on 1/26/2005.		
2. The allowed claim(s) is/are <u>12-19</u> .		
3. The drawings filed on 11 July 2003 are accepted by the Examiner.		
4.		
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/0 Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. Interview Summary Paper No./Mail Da 7. Examiner's Amenda 8. Examiner's Stateme 9. Other MICH	te

DETAILED ACTION

This Office Action is in response to an After Final Amendment filed on 3/7/2005.

Currently, claims 1-20 are present. Claims 15 and 20 has been canceled, and claims 1-11 have been withdrawn from consideration.

Election/Restrictions

1. This application is in condition for allowance except for the presence of claims 1-11 directed to a device that is non-elected without traverse. Accordingly, claims 1-11 have been cancelled.

Allowable Subject Matter

- 2. Claims 12-14 and 16-19 are allowed.
- 3. The following is an examiner's statement of reasons for allowance: the prior art, either singly or in combination fails to anticipate or render obvious, the limitations of:

... a silicon-rich silicon oxide layer, which is substantially opaque to UV radiation and has a refractive index (R. I.) greater than 1.6, on an upper surface of the interlayer dielectric, wherein the silicon-rich silicon oxide layer has a thickness of 400Å to 600Å, as required by claim 12.

The application is found allowable by the inclusion of allowable subject matter that was previously stated in canceled claim 20.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Walter L. Lindsay, Jr. whose telephone number is (571) 272-1674. The examiner can normally be reached on Monday-Thursday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Michael S. Lebentritt can be reached on (571) 272-1873. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

MICHAEL LEBENTRITT
SUPERVISORY PATENT EXAMINED